

Simulation and experimental characterization of the extraction of a focused broad ion beam from an inductively coupled plasma source

XXVIII. Erfahrungsaustausch OTPIP Mühlleithen 15th March 2023

K. M. Rettig^{1,2}, T. Dunger¹, E. Loos¹, M. Nestler¹, J. Schuster²

1: scia Systems GmbH, Chemnitz Germany

2: Fraunhofer Institute for Electronic Nano Systems ENAS, Chemnitz, Germany

scia systems Application – Ion Beam Trimming



- Focused broad ion beam for ion beam trimming (IBT) applications
- Ion beam width needs to match the applications topography error to be corrected
- Assist and accelerate the characterization, optimization and development of ion beams sources with simulations





scia systems Inductively coupled plasma chamber



- Inductively coupled plasma (ICP) inside the plasma chamber
- Potential difference in grid electrodes accelerates ions from the plasma towards the downstream area







- Inductively coupled plasma (ICP) inside the plasma chamber
- Potential difference in grid electrodes accelerates ions from the plasma towards the downstream area
- Plasma parameters calculated for the source geometry and operation conditions by a global plasma model
- Numerical simulation of the beam extraction from the plasma in equilibrium state



scia systems Global plasma model for gridded ICP



- Analytical model for determination of plasma parameters for ICP sources [1]
- Solving ordinary differential equations (ODE) for species densities and temperatures:
 - Particle balance of ions:

$$\frac{dn}{dt} = nn_{\rm g}K_{\rm iz} - nu_{\rm B}\frac{A_{\rm eff}}{V}$$

Particle balance of neutrals:

$$\frac{dn_{g}}{dt} = \frac{Q_{0}}{V} + nu_{B}\frac{A_{effion}}{V} - nn_{g}K_{iz} - \Gamma_{g}\frac{A_{g}}{V}$$

Neutral power balance:

$$\frac{d(\frac{3}{2}n_{\rm g}k_{\rm B}T_{\rm g})}{dt} = 3\frac{m_{\rm e}}{M}k_{\rm B}(T_{\rm e} - T_{\rm g})nn_{\rm g}K_{\rm el} - \frac{1}{4}Mu_{\rm B}^{2}nn_{\rm g}K_{\rm in} - \kappa(\frac{T_{\rm g} - T_{\rm g0}}{\Lambda_{\rm 0}})\frac{A}{V}$$

Electron power balance

$$\frac{d(\frac{3}{2}n_{\rm e}k_{\rm B}T_{\rm e})}{dt} = P_{\rm abs} - P_{\rm loss}$$

1: P. Chabert et al. Phys. Plasmas 19, 073512 (2012).

scia systems Global plasma model for gridded ICP



- Physical constants and properties of the inert gas
- Plasma chamber geometry (chamber, grid and coil geometry; grid transparency)
- Operation condition (gas flow rate; radio frequency (rf) power)







- Particle-in-cell and direct-simulation Monte-Carlo (PIC-DSMC) approach
- Time dependent macro-particle movement in E- and B-fields
- Multiple charged and neutral plasma species for coherent physical modeling
- Modeling of electron population in the plasma and the ion beam (for space charge compensation, SCC) via Boltzmann relation







- Multi-aperture three-grid extraction system
- Curved grids for geometric focus made from graphite with thicknesses of 0.5 and 1 mm
- Modeling of grids with <u>10 mm</u> and 37 mm diameter and single-aperture systems with a diameter of 1 mm









- Projection of 3D simulation only containing the position of ions (red)
- Full ion beam is interpolated from a simulation of a 30° piece of the full geometry (symmetry of the system is exploited to reduce the calculation time)
- Focus point visible after further examination







- Prediction of grid erosion and resulting changes in the extracted ion beam properties
- Evaluation of plasma properties at the extraction geometry → plasma sheath
- Characterization of the extracted ion beam







scia systems Comparison Experiment - Simulation

- Fraunhofer ENAS
- Using the same operation conditions for simulation and experiment (10 mm extraction grid, 100 W rf power, 1 sccm Ar-gas flow, 1.5 keV beam extraction)
- Evaluation of the beam width at various distances z from the ion source
- Fit of Gauss function at each beam cross section: standard deviation σ corresponds to beam width
- Investigation of a larger set of parameters: variation of rf power



scia systems Comparison Experiment - Simulation



- Two critical aspects for a comparison between experiment and simulation:
 - Power loss in the experimental configuration
 - Variable grid transparency for ions during power variation in global ICP model
- Accordance of beam current (current extracted through first extraction grid) only by considering variable transparencies for different applied rf powers







- Variation of rf power in experiment and simulation
- Evaluation of the beam width and ion current at a distance of z = 80 mm from the plasma source
- Consideration of variable grid transparency and constant power loss of 20 W



scia systems Comparison Experiment - Simulation

- Beam width comparison with constant 20 W and 40 W power loss
- Minor deviations in total beam width while differences in the trend are correct

correct power scaling required

experiment

100

7.0

beam width σ [mm] 79 9.9 8.9 8.9 8.9

6.0



150

200







- Theoretical model to predict ion beam properties based on source geometry and operation conditions
 - Global model for ICP to determine plasma parameters of the system
 - Numerical PIC-DSMC simulation of the beam extraction through a three-grid system
- Good agreement between experimental data and simulated ion beams









- Examination of the actual power loss
- Measuring plasma parameters in the chamber and in the beam for verification
- Improvement of the model to include a self consistent calculation of the grid transparency for ions
- Using the model for optimizations and further development of new ion sources



🗾 Fraunhofer

ENAS





scia systems

Thank you!

scia Systems GmbH Clemens-Winkler-Str. 6c 09116 Chemnitz Germany

▲ +49 371 33561-0
☑ info@scia-systems.com

www.scia-systems.com

scia systems

-

scia systems

100

SCIE

scia systems